

Remarks

Applicants and the undersigned reviewed the pending Office Action carefully, appreciate the Examiner's attention to detail and hereby amend the claims to alleviate various concerns raised. In addition, several other non-substantive amendments are hereby presented, merely to correct typographical error and promote better grammar and punctuation.

However, Applicants respectfully disagree as to the objection raised with claim 65. Please note that claim 65 is dependent upon claim 64. Antecedent basis for the "aryl" and "aryl lower alkyl" variations of R_{10} and R_{11} is found in claim 56 (i.e., at the top of page 14 of this response). The Examiner is invited to contact the undersigned by telephone if this concern has been misinterpreted or if further discussion would be useful.

Applicants appreciate the Examiner's conclusion that the claimed subject matter appears to be free of the prior art. Accordingly, all pending claims are now believed to be in condition for allowance and favorable action is respectfully requested. Again, the Examiner is invited to contact the undersigned by telephone should any issue remain. Thank you for your help and consideration.

Respectfully submitted,

/Rodney D. DeKruif/

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